1	Substrate Diffusion within Biofilms Significantly Influencing the Electron						
2	Competition during Denitrification						
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21

22 Abstract

A common and long-existing operational issue of wastewater denitrification is the 23 unexpected accumulation of nitrite (NO₂⁻) that could suppress the activity of various 24 microorganisms involved in biological wastewater treatment process and nitrous oxide 25 (N₂O) that could emit as a potent greenhouse gas. Recently, it has been confirmed that the 26 accumulation of these denitrification intermediates in biological wastewater treatment 27 process is greatly influenced by the electron competition between the four denitrification 28 steps. However, little is known about this in biofilm systems. In this work, we applied a 29 mathematical model that links carbon oxidation and nitrogen reduction processes through 30 a pool of electron carriers, to assess electron competition in denitrifying biofilms. 31 Simulations were performed comprehensively at seven combinations of electron acceptor 32 addition scheme (i.e., simultaneous addition of one, two or three among nitrate (NO₃⁻), 33 NO_2^- , and N_2O) to compare the effect of electron competition on NO_3^- , NO_2^- and N_2O 34 reduction. Overall, the effects of substrate loading, biofilm thickness and effective 35 diffusion coefficients on electron competition are not always intuitive. Model simulations 36 show that electron competition was intensified due to the substrate load limitation (from 37 120 to 20 mg COD/L) and increasing biofilm thicknesses (from 0.1 to 1.6 mm) in most 38 cases, where electrons were prioritized to nitrite reductase because of the insufficient 39 electron donor availability in the biofilm. In contrast, increasing effective diffusion 40 coefficients did not pose a significant effect on electron competition and only increased 41 electrons distributed to nitrite reductase when both NO₂⁻ and N₂O are added. 42

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 N_2

1/2Mred

r5

47 **1. Introduction**

Denitrification is a widely used process in wastewater treatment plant to achieve nitrogen 48 removal. The complete denitrification process consists of NO₃⁻ reduction to nitrogen gas 49 (N_2) , with NO₂, nitric oxide (NO) and N₂O as inevitable intermediates ¹. A common 50 operational issue of wastewater denitrification is the unexpected accumulation of NO₂-, 51 which could suppress the activity of various microorganisms involved in biological 52 wastewater treatment process and thus deteriorate the effluent quality ². Recently, the 53 accumulation and emission of another inevitable denitrification intermediate, N₂O, has 54 aroused great concern and attention, as N_2O is a potent greenhouse gas with a global 55 warming effect of ca. 300 times of carbon dioxide ³ and the dominant ozone-depleting 56 substance emitted in the 21st century ⁴. 57

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59 Recently, it has been confirmed that the accumulation of these denitrification intermediates is greatly influenced by the electron competition between the four 60 denitrification steps, i.e. NO_3^- to NO_2^- , NO_2^- to NO, NO to N_2O and N_2O to N_2^{5-7} . This is 61 because the four denitrification steps take electrons from a common electron source, and 62 therefore the relative ability of each denitrification step to compete for electrons would 63 regulate the electron distribution among the four denitrification steps and thus the 64 accumulation of the denitrification intermediate⁸. Further, other environmental factors, 65 such as pH, may exert differential effect on the activity of denitrification enzymes and 66 lead to changes of their ability to compete for electrons 9, 10. Therefore, a better 67 understanding of the electron competition process would give insights to the mechanisms 68

of denitrification intermediates accumulation, and help to develop better operationalstrategy of wastewater denitrification.

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Up to date, the reported investigations of electron competition have been focused on the 72 suspended-growth (including both pure and mixed culture) system such as activated 73 sludge process ^{5, 11, 12}. There is still a lack of knowledge about the attached-growth system, 74 75 such as the moving bed biofilm reactor (MBBR), integrated fixed-film activated sludge (IFAS), denitrifying filters, and granular sludge, which possess a large wastewater 76 treatment market. A noteworthy process feature of biofilm processes compared to 77 78 activated sludge processes is the fact that the performance of biofilm processes is often diffusion limited, while the process kinetics for the activated sludge process are generally 79 characterized by the bulk liquid concentrations. Thus, biofilm processes may behave 80 81 differently with respect to electron competition and denitrification intermediates accumulation in contrast to suspended-growth systems. In particular, the diffusion of 82 intermediates from one zone of the biofilm to another would lead to zones of certain 83 intermediates (e.g., NO₂⁻ or N₂O) formation or consumption transformations that would 84 not exist in suspended growth systems. 85

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To investigate the electron competition process in biofilms, the experimental work require measuring NO₃⁻, NO₂⁻and N₂O reduction at multiple points at different layers in biofilms, this could be quite challenging considering the structure complexity of the real biofilm system. Mathematical models are widely applied in biofilm systems and denitrification systems ¹³, and have been proved to be useful tools to study new process and provide strong support for the understanding and optimization of new technologies as already demonstrated previously ^{14, 15}. Recently, we have developed and validated a model, namely Activated Sludge Model for Indirect Coupling of Electrons (ASM-ICE) ¹⁶ to describe the electron competition process in denitrification systems, which has been successfully applied to reveal the mechanisms of N₂O formation and reduction in denitrifying biofilms ¹⁷. However, the detailed electron competition process in denitrifying biofilms is still not fully understood.

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100 Therefore, the main objective of this work is to perform a model-based assessment of 101 electron competition process during wastewater denitrification in biofilm systems, 102 through implementing ASM-ICE model in biofilms. In this study, we limit the biofilm 103 system to denitrification biofilm so that the electron competition process is evident. The 104 impacts of key operational parameters, including influent surface loading, biofilm 105 thickness and mass transfer coefficient on the electron competition process and N_2O 106 accumulation are investigated.

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108 2. Materials and Methods

109 2.1 Analysis of ASM-ICE model

The ASM-ICE model was developed and validated to describe the electron competition process using suspended-growth culture in bulk liquid systems ¹⁶. The key difference between ASM-ICE and the previous denitrification models, e.g., ASMN ¹⁸, is that the proposed model links carbon oxidation and nitrogen reduction processes through a pool of electron carriers, while the previous denitrification models directly couple the twoprocesses.

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The ASM-ICE model includes five reactions, r1- r5 (Figure 1), with r1 describing the 117 carbon oxidation process and r2 - r5 describing the nitrogen oxides (NO₃⁻, NO₂⁻, NO and 118 N₂O) reduction processes. Electron carriers, with Mox representing oxidized from of 119 electron carriers and Mred (Mred $= Mox + 2e^- + 2H^+$) representing reduced form of 120 electron carriers, are used in ASM-ICE model to link the carbon oxidation process and 121 the nitrogen oxides reduction processes. The carbon oxidation process (r1) provide the 122 electrons to Mox and reduce it back to Mred, while the nitrogen reduction process (r2 to 123 r5) draw electrons from Mred and oxidize Mred back to Mox. The four nitrogen oxides 124 125 reduction steps possess different abilities to compete for Mred, which is mainly affected by their affinity constants for *Mred*. It is believed that NO reductase has the highest 126 affinity constants, mainly due to NO reduction is usually prioritized by bacteria to avoid 127 its toxicity ¹³. Hence, the NO concentrations and rates will not be specifically addressed 128 in detail in this work due to the fact that NO would be quickly consumed and maintain at 129 near-zero concentrations. Experimental results also suggested that nitrite reductase has 130 131 higher ability to compete for electrons than nitrate and N₂O reductase. Model components are shown in Table S1 in Supporting Information (SI). Table S3 in the SI 132 shows the model matrices with kinetics and stoichiometrics. 133

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135 **2.2 Denitrifying biofilm model**

In this work the electron competition during denitrification process is incorporated into 136 biofilm system, with the ASM-ICE model being integrated into a biofilm compartment of 137 the software package (AQUASIM) for aquatic systems ¹⁹. AQUASIM is a program, in 138 which the spatial configuration of a model system can be represented by compartments, 139 which are connected by links. The program allows the user to define an arbitrary number 140 of substances to be modelled and it is extremely flexible in the formulation of 141 142 transformation processes. It is a finite difference method (FDM)-based software. Execution of a simulation is equivalent to numerically integrating a system of ordinary 143 and partial differential equations in time and simultaneously solving the algebraic 144 145 equations ¹⁹. The biofilm reactor was modelled through consisting of two different compartments, namely the biofilm and bulk liquid. The bulk volume and biofilm surface 146 of the reactor is 4 L and 50 dm², respectively. The influent flow rate was set at 4 L/day, 147 containing COD and nitrogen oxides. The biofilm compartment is limited to denitrifying 148 biofilms, so that the electron competitions between the nitrogen reductases are evident. 149 For simplicity, a one-dimensional stationary biofilm with fixed thickness was assumed in 150 all cases, without any biomass growth, attachment or detachment. Denitrifiers were 151 considered to be uniformly distributed throughout the biofilm, without diffusive mass 152 transport of biomass in the biofilm matrix. This approach has been well applied in 153 literature for describing biofilm systems ^{14, 17}. The water fraction of the biofilm matrix is 154 155 kept constant at 0.8, while the biomass density is 50 g/L. Parameters regarding the mass transfer coefficients for NO₃⁻, NO₂⁻, NO, N₂O and COD are adopted from Haynes ²⁰. 156 Twenty grid points in the biofilm were selected for calculation in specified compartment. 157 A simulation was defined for an active calculation with 2,000 steps of 1 day, which was 158

long enough to assure steady-state conditions. The biofilm and mass transfer parametersare shown in Table S2 in the SI.

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162 **2.3 Modeling approach and simulation scenarios**

Previously well-established parameter values of electron competition during 163 denitrification in ASM-ICE model that have been verified with experimental data are 164 used in this simulation study. Therefore, we directly adapt these parameter values and 165 kinetic rates into the model and evaluate the substrate and microbial interactions in the 166 denitrification biofilm system, which has been demonstrated to be a valid method in 167 previous studies ^{17, 21-23}. It should be noted that the applied set of parameters in this study 168 may not have a universal suitability for all denitrifiers due to the fact that the kinetic rates 169 may vary among different types of denitrifiers. However, the simulation results of this 170 171 work under different operational conditions are still useful for the understanding of electron competition in denitrification biofilm due to the fact that the possible variation of 172 biodegradation rates would not alter the overall trends based on the applied model 173 structure. Table S2 in the SI shows the definitions, values, units and sources of all 174 parameters used in the biological reaction model. Model simulations are then performed 175 under different operational conditions, namely COD loading, biofilm thickness and 176 effective diffusion coefficients (i.e., De/D, reduction factor of diffusion coefficients in the 177 biofilm compared to the aqueous phase). 178

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180 Methanol and various nitrogen oxides are supplied to the mixed liquor in each test. The 181 COD concentration in the influent ranges from 20 to 120 mg/L. The nitrogen oxides are 182 supplied according to the electron acceptor addition scheme (as shown in Table 1), with

the concentration in the influent being 20 mg N/L of each nitrogen oxide. Overall, seven 183 different electron acceptor addition method (i.e., simultaneous addition of one, two or 184 three among NO_3^- , NO_2^- , and N_2O) were applied, to provide data to compare the effect 185 of electron competition on NO3⁻, NO2⁻ and N2O reduction. Simulations were then 186 performed at different combinations of electron acceptor addition scheme, influent COD 187 concentration, biofilm thickness and effective diffusion coefficients to investigate 1) the 188 189 effect of COD concentration on electron competition; the effect of biofilm thickness on 190 electron competition; and 3) the effect of mass transfer on electron competition in biofilm.

Four different scenarios are considered (Table 1). The standard simulation scenario 192 (Scenario 0 of Table 1) is firstly performed to assess the potential electron competition in 193 biofilm with the initial COD concentration at 90 mg/L, biofilm thickness at 1mm and 194 195 D_e/D at 0.5. Scenarios 1- 3 in Table 1 examine the effects of influent COD concentration 196 (varied between 20-120 mg/L), biofilm thickness (0.1-1.6 mm) and mass transfer (De/D varied between 0.2-0.8) on electron competition in biofilms, respectively. In each 197 simulation, e.g., the influent COD concentration of 20 mg/L of Scenario 1, the simulation 198 were performed at seven different electron acceptor addition schemes, i.e. a) NO₃⁻ alone, 199 b) NO₂⁻ alone, c) N₂O alone, d) NO₃⁻ and NO₂⁻, e) NO₃⁻ and N₂O, f) NO₂⁻ and N₂O, and 200 finally g) NO₃⁻, NO₂⁻ and N₂O, to evaluate the electron distribution between different 201 202 nitrogen reduction reaction.

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204 **3. Results**

3.1 Electron competition in denitrifying biofilm

With the surface loading, biofilm thickness and effective diffusion coefficient set as in Scenario 0 (standard case), the model was first used to predict the nitrogen reduction in the biofilm to establish an overall picture of the electron competition process in the denitrifying biofilm.

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In general, the nitrogen compounds gradually reduced in the biofilm. For example, as 211 shown in Figure 2-a, when only NO_3^- was added, the NO_3^- concentration gradually 212 reduced from 20 mg N/L at surface of the biofilm to around 6 mg N/L at around 0.6 mm 213 of the biofilm and then gradually reduced to around 2 mg N/L at the bottom in the 214 215 biofilm. There were still some NO_3^- left at the bottom of the biofilm, since COD was completely consumed at around 0.2 mm of the biofilm as shown in Figure 2-h. In 216 comparison, when NO_2^- was added alone (Figure 2-b), the NO_2^- concentration gradually 217 reduced from 20 mg N/L at the surface of the biofilm to around 0 mg N/L at 0.25 mm of 218 the biofilm, while COD was still in excess at 0.25 mm (Figure 2-h). 219

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There were highly different accumulations of N_2O in Figure 2-a, 2b and 2d. In Figure 2-a (NO_3^- added alone), N_2O only accumulated to around 0.005 mg N/L, while in Figure 2-b (NO_2^- added alone), N_2O accumulated to around 0.015 mg N/L. The highest N_2O accumulation occurred in Case d (both NO_3^- and NO_2^- were added), up to almost 0.1 mg N/L, which is 20 times higher than that of Case a (Figure 2).

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227 One coherent observation was that the nitrogen oxide compound affects each other's 228 reduction rate. Take NO_3^- reduction for example, NO_3^- were added in Case a (Figure 2-a),

Case d (Figure 2-d) and Case g (Figure 2-g). The highest NO₃⁻ reduction rate was 229 observed in Case a when NO_3^- was added alone, with the NO_3^- concentration at around 2 230 mg N/L at the bottom of the biofilm. In comparison, the lowest NO_3^- reduction rate was 231 observed in Case g when three electron acceptors were all presented in the influent, with 232 the NO_3^- concentration at around 17 mg N/L at the bottom of the biofilm. Similar trend 233 also applies to NO₂⁻ and N₂O reduction. This is not surprising, as the more electron 234 acceptors were presented, the more severe electron competition would occur ²⁴. Therefore, 235 the rate of each denitrification step would be affected, clearly demonstrating the electron 236 competition in denitrifying biofilm. 237

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3.2 Impact of COD loading on electron competition in denitrifying biofilm

Considering that the availability COD would affect the supply of electron donor, the effect of COD concentration on electron distribution in denitrifying biofilm was investigated in Scenario 1 (Table 1). In this scenario, the COD concentrations in the influent were tested against 20, 40, 80, 90, 100, 110 and 120 mg/L. The simulation of each COD concentration was performed at seven different electron acceptor addition schemes, i.e. a) NO_3^- alone, b) NO_2^- alone, c) N_2O alone, d) NO_3^- and NO_2^- , e) NO_3^- and N_2O , f) NO_2^- and N_2O , and finally g) NO_3^- , NO_2^- and N_2O (as shown in Table 1).

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Three electron acceptor addition schemes (Case a, b and d) were presented in detail in Figure 3, including the simulation results of nitrogen oxides profile, COD profile and electron distribution pattern, to reveal the effect of COD concentration on electron distribution in the denitrifying biofilm system. 252

253 *Case a:* When NO_3^- was added alone as electron accepter, the electron distribution among 254 nitrate reductase (Nar), nitrite reductase (Nir) and N₂O reductase (Nos) remained at a 255 constant level (Figure 3-IV). The corresponding COD consumption profile (Figure 3-III) 256 reveals that COD was either in excess at the bottom of the biofilm or completely 257 consumed at outer layer of the biofilm. These results together suggest that when NO_3^- was 258 added alone, the electron distribution was not affect by the COD loading.

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Case b: When only NO_2^- was added as electron accepter, the electron distribution 260 261 presented two distinct patterns (Figure 3-iv). The electrons distributes to Nir accounted for around 85%, when the influent COD was below 40 mg/L. Contrarily, when the 262 influent COD was above 80 mg/L, the electrons distributes to Nir only accounted for 263 264 around 65%. By analyzing the COD to N ratio, it is obvious that the COD was not sufficient for complete nitrite denitrification when COD was below 40 mg/L and thus the 265 electron completion would be more severe than those tests with sufficient influent COD 266 for complete NO_2^- reduction, i.e. COD concentration above 80 mg/L. 267

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Case d: when both NO_3^- and NO_2^- were added as electron accepter, COD was not enough for NO_3^- and NO_2^- reduction in all the cases (As shown in Figure 3-3). However, the COD influent concentration would still affect the N₂O accumulation. As shown in Figure 3-1 and Figure 3-2, the N₂O accumulates to around 0.15 mg/L with influent COD at 20 mg/L and only about 0.01 mg/L with influent COD at 120 mg/L. Similar to Case b 274

(Figure 3-iv), less COD present in the influent would lead to more electrons distributed to Nir (Figure 3-4)

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The electron distribution patterns of the 7 electron additions schemes are summarized in 277 Figure S1 in the SI. In general, all the results suggested that the electron distribution was 278 significantly affected by the COD loading in most of the cases. A coherent trend is that 279 when COD loading reduced from 120 mg/L to 20 mg/L, the electrons distributed to 280 nitrite reductase would increase, except for Case e (adding NO₃⁻ and N₂O). This is likely 281 due to that the reduced COD loading would decrease the supply of electron donor, and 282 283 thus intensify the electron competition. Nitrite reductase (Nir), with affinity constant to electrons of 0.00040 mmol/(mmol biomass), has higher ability to compete for electrons 284 than nitrate reductase (Nar) and N₂O reductase (Nos) with their affinity constants being 285 286 0.0046 and 0.0032 mmol/(mmol biomass), respectively ¹⁶. Therefore, the electrons distributed to NO₂⁻ increased when COD loading gradually reduced. In Case e, NO₂⁻ was 287 resulted from NO₃⁻ reduction. The reduced COD loading led to more electrons to N₂O 288 reduction and thus less electrons were distributed to Nir. 289

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3.3 Impact of biofilm thickness on electron competition in denitrifying biofilm

292 Considering that the biofilm thickness would affect various aspects of substrate/product 293 distribution and diffusion in biofilm systems, the effect of biofilm thickness on electron 294 competition was explored in Scenario 2 (Table 1). In this scenario, with other parameters 295 (i.e., influent COD concentration and effective diffusion coefficients) kept constant, the 296 biofilm thicknesses were tested against 0.1, 0.4, 0.7, 1.0, 1.3 and 1.6 mm (Table 1). The simulation of each biofilm thickness was performed at seven different electron acceptoraddition schemes as shown in Table 1.

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Three electron acceptor addition schemes (Case a, b and d) were presented in detail in Figure 4, including the simulation results of nitrogen oxides profile, COD profile and electron distribution pattern, to reveal the effect of biofilm thickness on electron distribution in the denitrifying biofilm system.

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Case a: Comparing the results from Figure 4-I, II and III, it is clear that the biofilm 305 306 thickness would affect the NO3⁻ and COD concentration profile. Greater biofilm thicknesses resulted in steeper NO₃⁻ and COD concentration gradient in the biofilm, 307 which is probably due to better substrate penetration along the biofilm. For example, 308 309 when the biofilm thickness is 0.4 mm, the NO_3^- concentration only reduced by 4.5 mg/L from 20 mg/L at 0.4 mm to 15.5 mg/L at 0 mm (Figure 4-I). In comparison, when the 310 biofilm thickness is 1.6mm, the NO_3^- concentration reduced by 13.5 from 20 mg/L at 311 1.6mm to 7 mg/L at 1.2mm (Figure 4-II). Figure 4-III reveal that COD was either in 312 excess at the bottom of the biofilm or completely consumed at the outer layer of the 313 biofilm. Figure 4-IV indicates that the biofilm thickness has no significant influence on 314 the electron distribution when only NO_3^- is added. 315

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317 *Case b:* Similar to Case a, greater biofilm thicknesses had steeper NO_2^- and COD 318 concentration gradient (Figure 4-i and ii). COD was in excess in all the biofilm ranges, as 319 indicated by Figure 4-iii. Figure 4-iv reveals that greater biofilm thicknesses led to less 320

electrons distributed to Nir. Therefore, the trend is regardless of the COD concentration,

and only the biofilm thickness affects the electron distribution.

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Case d: Similar to Cases a and b, greater biofilm thicknesses had steeper NO₃⁻, NO₂⁻ and 323 COD concentration gradient (Figure 4-1 and 2). The COD profile shows that when the 324 biofilm thickness is 1.6 mm, COD was completely consumed. However, when the 325 biofilm thickness is 0.4 mm, COD was in excess at the bottom of the biofilm. The results 326 of this case study suggest that the electron distribution is not only affected by the biofilm 327 thickness, but also by the COD availability which is also correlated to biofilm thickness. 328 Figure 4-4 suggests that greater biofilm thicknesses resulted in more electrons distributed 329 to Nir. 330

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332 The electron distribution patterns of the 7 electron additions schemes are compared in Figure S2 in the SI. In Case d (i.e., add NO₃⁻ and NO₂⁻), Case e (i.e., add NO₃⁻ and N₂O) 333 and Case g (i.e., add NO3-, NO2- and N2O), greater biofilm thicknesses led to more 334 electrons distributed to Nir, due to the insufficient COD availability in the thicker biofilm 335 that increased electron competition. In contrast, in Case b (add NO₂⁻ alone) and Case f 336 337 (add NO₂⁻ and N₂O alone), greater biofilm thicknesses resulted in less electrons distributed to Nir, as thicker biofilms had greater N₂O reduction in the deeper layer of the 338 biofilm and more electrons were thus distributed to Nos. 339

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341 **3.4 Impact of mass transfer on electron competition in denitrifying biofilm**

The different biofilms might possess different mass transfer capabilities. Compact biofilm may have lower mass transfer ability. Therefore, this section explores the effect of mass transfer on the electron competition (Scenario 3 in Table 1). In this scenario, with other parameters (i.e., influent COD concentration and biofilm thickness) kept constant, D_e/D were tested against 0.2, 0.3, 0.4, 0.5, 0.6, 0.7 and 0.8 (Table 1). The simulation of each D_e/D was performed at seven different electron acceptor addition schemes as shown in Table 1.

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Three electron acceptor addition schemes (Case d, f and g) were presented in detail in Figure 5, including the simulation results of nitrogen oxides profile, COD profile and electron distribution pattern, to reveal the effect of effective diffusion coefficient on electron distribution in the denitrifying biofilm system.

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Case d: when both NO_3^- and NO_2^- were added as electron accepter, COD was sufficient at a D_e/D of 0.8 (Figure 5-III). When D_e/D was lower than 0.8, COD was insufficient for nitrogen oxide reduction and higher accumulation of N_2O was found in the biofilm, i.e., 10 mg-N/L at a D_e/D of 0.3 vs 7 mg-N/L at a D_e/D of 0.8 (Figure 5-I and II), probably due to the penetration limitation of COD. However, the electron distribution pattern was not substantially affected by D_e/D in Case d (Figure 3-IV).

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362 *Case f:* when both NO_2^- and N_2O were added as electron accepter, COD was not enough 363 for NO_2^- and N_2O reduction in all the cases (Figure 5-iii). Similar to Case d, NO_2^- 364 concentration gradient decreased with the increased D_e/D (Figure 5-i and ii), i.e., NO_2^- became zero, at 0.4 mm at a D_e/D of 0.3, and at the bottom at a D_e/D of 0.8. The electron distribution pattern was substantially affected by D_e/D in Case f, i.e., greater D_e/D resulted in more electrons distributed to Nir.

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369 *Case g:* Similar to Case d and f, lower D_e/D had steeper NO_2^- and COD concentration 370 gradient (Figure 5-1 and 2). COD was limited in all the D_e/D ranges, as indicated by 371 Figure 5-3. In contrast to Case f, the electron distribution pattern was not substantially 372 affected by D_e/D (Figure 5-4).

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The electron distribution patterns of the 7 electron additions schemes are compared in Figure S3 in the SI. There is no significant change of the electron competition, except for Case f when both NO_2^- and N_2O are added. In Case f, deeper penetration of NO_2^- to the bottom of the biofilm as a result of increased D_e/D would consume more electrons and thus more electrons were distributed to Nir.

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380 **4. Discussion**

Benitrification process is an important step during biological nitrogen removal. However, the unbalance between the electron supply and consumption, particularly under a limited electron supplying flux, would lead to deteriorated denitrification, i.e., accumulation of NO_2^- and N_2O^{-16} . In this work, a previously-established approach that decouples the carbon oxidation with four-step nitrogen oxides reduction processes through the introduction of electron carriers was applied to describe electron competition in the different electron acceptors (i.e., simultaneous addition of one, two or three of NO_3^- , NO₂⁻ and N₂O) during denitrification in denitrifying biofilm.

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The results clearly indicate that the mechanisms of electron competition in the 390 denitrifying biofilms are highly different from those in suspended-growth processes ²⁵, 391 where NO₂⁻ reduction was prioritized over the other denitrification steps when electron 392 supply became the limiting step. In a suspended-growth system without substrate 393 diffusion, the fractions of electrons distributed to nitrite reductase increased with the 394 decrease of electron supply rate, thus resulting in accumulation of other nitrogen oxide 395 intermediates. This could be attributed to a higher capacity of NO₂⁻ reduction for electron 396 competition under electron limiting conditions (i.e., a low S_{Mred} concentration), 397 398 specifically, K_{Mred.2} (S_{Mred} affinity constant for Nir) has a value that is approximately ten 399 times lower than $K_{Mred,1}$ (S_{Mred} affinity constant for Nar) and $K_{Mred,4}$ (S_{Mred} affinity constant for Nos) ²⁵. 400

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A key difference between attached- and suspended-growth processes is that in a biofilm, 402 nitrogen oxide intermediates generated during denitrification can diffuse according to 403 substrate gradients ¹⁷. This can further impact electron competition during denitrification 404 in the biofilm. In particular, COD loading, biofilm thickness and effective diffusion 405 coefficients can affect the substrate diffusion in the biofilm and in turn impact electron 406 competition. With the increasing scarcity of electron donors in the biofilm (i.e., COD 407 loading from 120 mg/L to 20 mg/L), the electrons distributed to nitrite reductase 408 increased in most addition schemes in the biofilm, similar to the suspended-growth 409

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limited.

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The inherent property of biofilm also altered the electron competition tendency compared 415 to that of the suspended-growth system. Increasing biofilm thicknesses had more 416 electrons distributed to NO_2^- reduction in most addition schemes, due to the insufficient 417 electron donor availability in the thicker biofilm. In contrast, in Case b (add NO2⁻ alone) 418 and Case f (add NO₂⁻ and N₂O), less electrons distributed to Nir with the increase of 419 biofilm thicknesses, likely due to the stronger N₂O sink as a result of greater biofilm 420 thicknesses. In comparison, increased effective diffusion coefficients only affected 421 electrons distributed to Nir in Case f when both NO₂⁻ and N₂O are added. The electrons 422 distributed to Nir increased with the increase of effective diffusion coefficients due to the 423 better penetration of NO₂⁻ to the biofilm. 424

process. However, in Case e (adding NO₃⁻ and N₂O), it led to a contrary trend, which

could be explained by the fact that NO₂⁻ was not present at the beginning and more

electrons were distributed to N₂O reduction compared to NO₃⁻ reduction if electrons were

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The biofilm processes have been widely used in wastewater treatment plants (WWTPs), such as MBBR, IFAS, denitrifying filters, and granular sludge. Substrate diffusion limitation is often observed in biofilm processes, which may behave differently in terms of electron competition and denitrification intermediate accumulation in contrast to activated sludge processes. This study would help to understand and develop the effective strategies to reduce the accumulation of unfavorable denitrification intermediates, particularly N₂O. For a biofilm denitrifying system, alternating effective diffusion

coefficients would not significantly affect electron competition and thus alleviate the N2O 433 accumulation except that only NO₂⁻ and N₂O are presented in the influent from nitrifying 434 reactor. In comparison, decreasing biofilm thickness would be a useful way to reduce 435 N_2O accumulation in most cases. However, if NO_2^- alone or NO_2^- with N_2O is in the 436 influent, on the contrary, increasing biofilm thickness would alleviate N₂O accumulation. 437 In addition, it should be revealed that, increasing COD loading, one common strategy 438 used to alleviate N₂O accumulation in activated sludge processes, might not still work in 439 biofilm systems with NO_3^- alone or NO_3^- and N_2O in the influent. 440

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442 The objective of this work is to provide insights into electron competition during denitrification in biofilms. Ideally, the above goal in this study would be achieved if the 443 model could be calibrated using experimental data. This is unfortunately not possible at 444 445 present due to the lack of data. We have therefore chosen to conduct a simulation study by integrating well-established models describing electron competition during 446 denitrification. We recognize that without being validated with data, the model 447 predictions are preliminary and remain to be verified. However, we believe the 448 preliminary results will already support our understanding in this process. Further efforts 449 should be devoted to conducting experimental work to support the hypotheses produced 450 by this modeling work in future. 451

452

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461 Supporting information

462 Model components, parameter values and model matrices in Table S1-S3, and additional

463 experimental data in Figure S1-S3.

464

465 **Conflict of Interest Disclosure**

466 The authors declare no conflict of interest.

467

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540

- 541 **Table Caption**
- 542

Table 1: An overview of the simulation scenarios and electron acceptor addition scheme

545 Figure Captions

546

Figure 1. Simplified representation of the biochemical reactions associated with electroncompetition during denitrification.

549

Figure 2. Model simulation results of the nitrogen oxides reduction (a-g) and the COD
consumption in denitrification biofilm (h). Electron acceptor addition scheme: a) Add
NO₃⁻ alone, b) add NO₂⁻ alone, c) add N₂O alone, d) add NO₃⁻ & NO₂⁻, e) add NO₃⁻ &
N₂O, f) add NO₂⁻ & N₂O, and g) add NO₃⁻, NO₂⁻ & N₂O. The surface of the sediment was
defined as depth 1 mm.

555

Figure 3. The effect of COD concentration on nitrogen oxides reduction (I~II, i~ii and 1~2), COD consumption (III, iii and 3), and electron distribution between Nar, Nir and Nos (IV, iv and 4). I~ IV show the simulation results of Case a, with only NO_3^- presenting in the influent. i~ iv show the simulation results of Case b, with only NO_2^- presenting in the influent. 1~4 show the simulation results of Case d, with both NO_3^- and NO_2^- in the influent. The surface of the sediment was defined as depth 1 mm.

562

Figure 4. The effect of biofilm thickness on nitrogen oxides reduction (I~II, i~ii and 1~2),

564 COD consumption (III, iii and 3), and electron distribution between Nar, Nir and Nos (IV,

iv and 4). I~ IV show the simulation results of Case a, with only NO_3 - presenting in the

influent. i~ iv show the simulation results of Case b, with only NO_2^- presenting in the influent. 1~4 show the simulation results of Case d, with both NO_3^- and NO_2^- in the influent. The bottom of the sediment was defined as depth 0 mm.

569

- **Figure 5.** The effect of mass transfer on nitrogen oxides reduction (I \sim II, i \sim ii and 1 \sim 2),
- 571 COD consumption (III, iii and 3), and electron distribution between Nar, Nir and Nos (IV,
- iv and 4). I~ IV show the simulation results of Case d, with NO_3^- and NO_2^- presenting in
- the influent. i~ iv show the simulation results of Case f, with NO_2^- and N_2O presenting in
- the influent. $1\sim4$ show the simulation results of Case g, with NO₃⁻, NO₂⁻ and N₂O present
- in the influent. The surface of the sediment was defined as depth 1 mm.

576

Scenario	S	Star	ndard condition	ons	Variable conditions			
Scenario Standard	0 simulation	CO L _f = D _e /I	COD = 90 mg/L $L_{f} = 1 \text{ mm}$ $D_{e}/D = 0.5$					
Scenario Effect of concentr	1 COD ation on elect ion	ron D_e/I	= 1 mm D = 0.5		COD=20-120			
Scenario Effect of on electr	2 biofilm thick on competition	$ \begin{array}{c} \text{CO}_{\text{c}} \\ \text{cness} \\ \text{D}_{e} \\ \end{array} $	D = 90 mg/L D = 0.5		L _f =0.1-1.6			
Scenario Effect of electron biofilm	3 Smass transfe competition i	r on CO n $L_f =$	COD = 90 mg/L $L_f = 1 \text{ mm}$ $D_e/D = 0.2-0.8$			8		
Electron acceptor addition scheme								
a	b	c	d	e	f	g		
NO ₃ -	NO ₂ -	N ₂ O	NO ₃ - NO ₂ -	NO ₃ - N ₂ O	NO ₂ - N ₂ O	NO3 ⁻ NO2 ⁻ N2O		

Table 1: An overview of the simulation scenarios and electron acceptor addition scheme



C oxidation

Figure 1. Simplified representation of the biochemical reactions associated with electron competition during denitrification.

247x189mm (96 x 96 DPI)



Figure 2. Model simulation results of the nitrogen oxides reduction (a-g) and the COD consumption in denitrification biofilm (h). Electron acceptor addition scheme: a) Add NO3 alone, b) add NO2- alone, c) add N2O alone, d) add NO3 & NO2-, e) add NO3 & N2O, f) add NO2- & N2O, g) add NO3 , NO2- & N2O. The surface of the sediment was defined as depth 1 mm.

243x316mm (96 x 96 DPI)



Figure 3. The effect of COD concentration on nitrogen oxides reduction (I~II, i~ii and 1~2), COD consumption (III, iii and 3), and electron distribution between Nar, Nir and Nos (IV, iv and 4). I~ IV show the simulation results of Case a, with only NO3 presenting in the influent. i~ iv show the simulation results of Case b, with only NO2– presenting in the influent. 1~4 show the simulation results of Case d, with both NO3 and NO2– in the influent. The surface of the sediment was defined as depth 1 mm.

263x237mm (96 x 96 DPI)



Figure 4. The effect of biofilm thickness on nitrogen oxides reduction (I~II, i~ii and 1~2), COD consumption (III, iii and 3), and electron distribution between Nar, Nir and Nos (IV, iv and 4). I~ IV show the simulation results of Case a, with only NO3 presenting in the influent. i~ iv show the simulation results of Case b, with only NO2– presenting in the influent. 1~4 show the simulation results of Case d, with both NO3 and NO2– in the influent. The bottom of the sediment was defined as depth 0 mm.

246x238mm (96 x 96 DPI)



Figure 5. The effect of mass transfer on nitrogen oxides reduction (I~II, i~ii and 1~2), COD consumption (III, iii and 3), and electron distribution between Nar, Nir and Nos (IV, iv and 4). I~ IV show the simulation results of Case d, with NO3 and NO2 presenting in the influent. i~ iv show the simulation results of Case f, with NO2 and N20 presenting in the influent. 1~4 show the simulation results of Case g, with NO3, NO2 and N20 present in the influent. The surface of the sediment was defined as depth 1 mm.

263x270mm (96 x 96 DPI)